Supporting Information

for

Optically tunable Mie-resonance VO₂ nanoantennas for metasurfaces in the visible

Peter Kepič,^{†,‡} Filip Ligmajer,^{*,†,‡} Martin Hrtoň,^{†,‡} Haoran Ren,[§] Leonardo de S. Menezes,^{§,∥} Stefan A. Maier,^{§,⊥} Tomáš Šikola^{+,‡}

- + Central European Institute of Technology, Brno University of Technology, 612 00 Brno, Czech Republic
- Institute of Physical Engineering, Faculty of Mechanical Engineering, Brno University of Technology, 616 69
 Brno, Czech Republic
- § Chair in Hybrid Nanosystems, Nanoinstitute Munich, Faculty of Physics, Ludwig-Maxilimians-Universität München, 80539 München, Germany
- Departmento de Física, Universidade Federal de Pernambuco, 50670-901 Recife-PE, Brazil
- $^{\perp}\,$ Department of Physics, Imperial College London, London SW7 2AZ, United Kingdom
- * E-mail: <u>filip.ligmajer@ceitec.vutbr.cz</u>



Figure S1. Simulated scattering cross-section spectra of single VO_2 nanodiscs with varying height (100 nm - 300 nm) and diameter (100 nm - 300 nm) in the low-temperature phase (top) and in the high-temperature phase (bottom).



Figure S2. Forward-to-backward scattering cross-section ratio calculated for an array of VO₂ nanodiscs in the low-temperature phase (nanodisc height h = 200 nm, diameter D = 270 nm, pitch P = 1.5D).



Figure S3. (a) Full width at half maximum (FWHM) of the scattering (single nanodiscs, solid lines) and extinction (nanodisc arrays, dashed lines) resonances, as extracted from Gaussian fits to the respective measured spectra shown in the main article. Note that when higher-order resonances became apparent in the spectra of larger nanodiscs, we used two Gaussian functions for the fit but we report here the FWHM only for the dipolar (long wavelength) resonance. (b,c) Modulation depths corresponding to the VO₂ phase change, defined as $10\log(I_{LT}/I_{HT})$, calculated directly from the single nanodisc scattering spectra (b) and the nanodisc array extinction spectra (c).



Figure S4. Multipole extinction decomposition of LT (left) and HT (right) VO₂ nanodisc array on a fused silica substrate (nanodisc height h = 200 nm, diameter D = 270 nm, pitch P = 1.5D).